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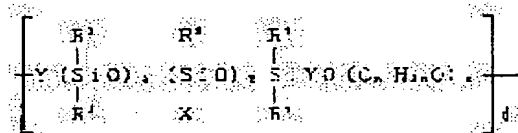
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## (54) SKIN COSMETIC

## (57)Abstract:

**PROBLEM TO BE SOLVED:** To obtain a skin cosmetic good in the sustainability of excellent skin touch and causing no messy makeup due to sweat.

**SOLUTION:** This skin cosmetic contains 0.01-80 (pref. 0.1-40)wt.% of a reactive silicone-based block copolymer of the formula [R1 is a monovalent hydrocarbon free from aliphatic unsaturated bond; X is a reactive functional group of the formula R3-Z (R3 is a direct bond or a 1-20C divalent hydrocarbon; Z is an amino-contg. group or an epoxy-contg. group); R2 is the same as either of R1 or X; (n) is 2-4; (a)>2; (b)>1; (c)>4; (d)>4; Y is a divalent organic group bound to a polyoxyalkylene block]. Formulation of the block copolymer after being dissolved or dispersed in a volatile cyclic silicone in advance gives the objective skin cosmetic easy to handle and good in compatibility with the skin. This skin cosmetic can be prepared into such a form as cleaning cream, cold cream, hand cream, powder, face lotion, foundation, mascara, eyeshadow, lotion, rouge, manicure, anti-suntan cream, or anhidrotics.



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